Receipt date: 10/04/2006

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Sheet 1 of I

FORM 1449*	
	INFORMATION DISCLOSURE STATEMENT

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Docket Number:

Application Number: UNKNOWN

10599658 - GAU: 2814

IN AN APPLICATION

(Use several sheets if necessary)

Applicant: TAKEUCHI et al.

Filing Date: concurrent herewith

Group Art Unit: UNKNOWN

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EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
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PATENT TRADEMARK OFFICE

/Eva Montalvo/ **EXAMINER**

DATE CONSIDERED

11/26/2008

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.